b.i.	What is a Light Emitting diode (LED)? Describe the principle, construction an LED.	d working of (8 Marks)
ii.	Write a note on diffusion and drift current.	(4 Marks)
30. a.	Explain the absorption and emissions processes with necessary theory and her relation between Einsteins coefficients.	ce derive the
	(OR)	-
b.i.	Describe the theory of Drudes model and hence derive the expression conductivity.	for electrical (10 Marks)
ii.	Mention any two applications of photovoltaic effect.	(2 Marks)
31. a.	Describe the Linear and Vander Pauw Four Point Probe technique f measurements.	or electrical
b.	(OR) What are the fundamental laws of absorption? Describe the principle, consworking of UV Visible Spectrophotometer.	struction and
32. a.i.	What are Carbon nanotubes (CNT)? Mention the properties of CNTs.	(4 Marks)
ii	ii. Describe the fabrication of CNT's by Physical Vapor Deposition (PVD).	(8 Marks)
÷	(OR)	
b.i.	Describe the principle, construction and working of Scanning Electron Microsco	pe (SEM).
••	N77.'4	(8 Marks)
11.	Write a note on Heterojunctions.	(4 Marks)

	- (
Reg. No.							
		 	 			 	

B.Tech. DEGREE EXAMINATION, NOVEMBER 2018

First Semester

18PYB103J - PHYSICS: SEMICONDUCTOR PHYSICS

(For the candidates admitted during the academic year 2018-2019)

Note:	•		
over to hall invigilator at the		the end of 45 th minute.	first 45 minutes and OMR sheet should be handed
(ii)	Part - B and Part - C sho	ould be answered in answer	booklet.
Time:	Three Hours		Max. Marks: 100
		PART – A (20 × 1 = 2 Answer ALL Que	
	The average distance trappersence of applied field	*	etween two successive collisions in the
	(A) Collision time	(B)	Mean free path
	(C) Wave number	(D)	Drift velocity
	The band gap is called same in both the cond photon.		stal momentum of electrons and holes is the ence band; an electron can directly emit a
	(A) Direct	(B)	Indirect
	(C) Crystalline	(D)	Noncrystalline
	3 is temperature above 0K.	the state at which the r	probability of electron occupation is ½ at any
	(A) Valence level	(B)	Fermi level
	(C) Conduction level	(D)	Density of states
	field or magnetic field,	then the mass of the elec	
	(A) Rest mass		Effective mass
	(C) Zero mass	(D)	Accelerated mass
	5. is a PN	Junction, which is forward	ard biased?
	(A) Light Emitting dio		
	(C) Rectifier		Transistor
		ipon a semiconductor the contact which leads	o create electron – hole pairs, some of the to
	(A) gain	(B)	photocurrent
	(C) amplification	(D)	biasing
	7. Which type of material impurity?	is obtained when intrin	sic semiconductor is doped with pentavalent
	(A) N-type semicondu	ctor (B)	Extrinsic semiconductor

(D) Insulator

(C) P-type semiconductor

8.			-	of radi	ative recombination of electron-hole pairs
		ted by electron bon		(D)	Cathodoluminescence
•	` ′	Photoluminescence		` '	
	(C)	Electroluminescer	ice	(D)	Anodoluminescence
9.		spectral region, whorbing is known as		changes	from being relatively transparent to strongly
	(A)	Absorption edge			Conduction edge
	(C)	Valence edge		(D)	Annihilation edge
l 0 .		ording to Drudes the city given by kineti			electrons are assumed to have
		Root mean square		` ′	Drift
	(C)	Instantaneous		(D)	Uniform
1.		is the cr	eation of voltage	e and ele	ctric current in a material upon exposure
		ght and is a physica	l and chemical p		
	` · ·	Acousto- optics		,	Photovoltaics
	(C)	Electrolysis		(D)	Electrophorsis
12.			the states at wh		fe time of atoms is extended is
	` ,	Metastable state			Stable state
	(C)	Dense state		(D)	Excited state
13.	prob	determining the re e and the semicond Smaller than			the gap between the probes. Greater than
	` '	Equal to			Double
4.	(C)	. •	tachniqua for	` ,	rizing semiconductor materials and devices,
· T.					citance is measured and plotted as a function
	(A)	Capactive - voltag	e profiling	(B)	Current profiling
	(C)	Voltage profiling	•	(D)	Baising
5.	A	is a r	method of determ	nining q	uickly whether a semiconductor sample is n
	(neg	ative) type or p (po			· · ·
	(A)	Electrolysis		(B)	Hot point probe
	(C)	Rectification		(D)	Hydrogenation
6.					of monochromatic light passes through an
	prop	ortional to the inter			ensity with the thickness of the medium, is
		Lambert's		` '	Beer's
	(C)	Photoelectric		(D)	Snell's
7.	None	onarticles are speci	al mainly becaus	o of their	· . •
		-	ur mann, ovvas		
	(A)	Surface area	ar manny coour	(B)	Surface charge
	(A)	-	ur mumi, 000000	(B)	

					•
18.	In a quantum wire, the ma		To the distriction		
	(A) In three directions(C) In one direction		In two directions Infinitely		•
	(C) In one direction	(D)	minimicity .		
19.	In CVD chamber, the prostate.	ecursors are introduced	to the reaction ch	amber in t	he
	(A) Liquid	(B)	Solid		
	(C) Semisolid	(D)	Gaseous		
20.	The physical parameter	that is probed in Al	M resulting from	different	interactions is
	(A) Charge	(B)	Force		
	(C) Potential	• • • • • • • • • • • • • • • • • • • •	Field		
		$PART - B (5 \times 4 = 20)$) Marks)	. •	
		Answer ANY FIVE			
21.	Write a note on Energy ba	ands in solids.			
22.	Describe the nonequilibri	um properties of carrie	rs.		
23.	What is a PN Junction? E	xplain the biasing cond	ept in PN Junction	•	
24.	Write a note on organic li	ght emitting diodes.			
25.	Describe the optical absor	rption and recombination	on process.	, -	
26.	Write a note on I-V chara	cteristics of a diode.			
27.	Describe the powder meth	hod of X-ray diffraction	1.		•
		$PART - C (5 \times 12 = 6)$ Answer ALL Que	•		
8.a.i.	What is Density of states material.	s? Derive an expression	n for density of st	ates for a	semiconducting (10 Marks)
ii.	The Fermi level for pota-	ssium is 1.9 eV. Calcu	late the velocity of	f the electr	on at the Fermi (2 Marks)

(OR)

- b. Describe the behavior of electron in a periodic potential and hence explain the Kronig Penny Model in detail with the cases.
- 29.a.i. What is an extrinsic semiconductor? Describe the variation of Fermi level with carrier concentration and temperature in an N-Type semiconductor.
 - ii. Determine the position of the Fermi Level in an instrinsic semiconductor from the centre of forbidden gap at room temperature, if the effective mass of an electron is equal to twice the effective mass of hole.